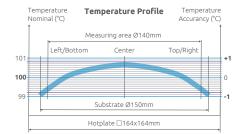


Hotplate HP-150 Precise soft & hard baking



Wafer Clean & Primer	Photoresist & Soft Bake	Mask Alignment & Exposure	Post Bake & Develop	Etch & Hard Bake	Stripping	Clean & Inspection
Spin Rinser Dryer	1 1	•		Developer	Developer-Etch	Spin Rinser Dryer
Hotplates (Dehumidifier)	Spray Coater Hotplates		Developer	Developer-Etch Hotplates		



The **Hotplate HP-150** was developed for typical soft bake and hard bake processes in lithography, in MEMS and similar applications. The temperature range is designed for up to 250°C by default. The set temperature and the temperature profile have narrow margins, meaning that a high coating quality can be achieved. The HP series is convincing due to its high level of uniformity and the high-precision process repeatability. It can be used for substrates with a diameter of up to 150mm and thicknesses of 5mm at maximum.

The hotplate is covered with safety glass, which makes cleaning easier. Due to the high-quality and robust design and easy handling, SAWATEC hotplates are preferentially used for laboratories, R&D, pilot projects and institutes.

The high-precision, good value instruments are available both as portable bench-top and bench-mounted units.



FEATURES (BASIC CONFIGURATION)

- ▶ Temperature control with digital target and actual value display
- Automatic temperature limit switch, no overheating
- Hotplate with safety glass, easy cleaning
- Easy levelling of the hotplate, prevents discharge of photoresist
- ► Manual substrate fixation via vacuum
- ▶ Manual loading and unloading of the substrates



PERFORMANCE DATA

- ▶ Temperature range: ambient temperature up to 250°C
- ► Temperature accuracy: +/- 1°C at 100°C

ADDITIONAL FUNCTIONS (OPTIONS)

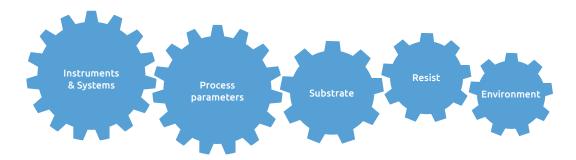
▶ N2 flushing manually controlled, no oxidation



INTERACTION OF THE PROCESS PARAMETERS

To ensure that a high level of process reliability can be reached, the interaction of our products with the defined process parameters, the selected substrate and the photoresist must be perfectly co-ordinated.

Furthermore, the process environment exerts a great influence on the process quality, therefore the ambient temperature, the exhaust and supply air (laminar flow) and all technical connections (N2, compressed air...) must be designed optimally.



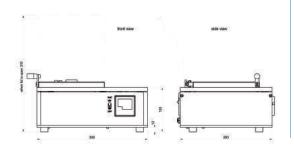
DESIGN AND DIMENSIONS

Bench-top unit HP-150-BT

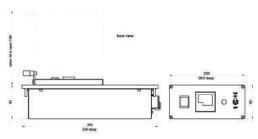
- Bench-mounted unit HP-150-BM
- Compact, space-saving design
- ▶ Hotplate: 164 x 164 mm, anodised aluminium
- ► Housing: anodised aluminium
- Cover: manually operated, anodised aluminium
- ▶ Integrated fan
- Dimensions: 300 x 250 x 120mm (L x B x H)
- ▶ Weight: ca. 7kg

- Mounting module: 360 x 330 x 90mm (L x B x H)
- Mounting panel: 200 x 90 x 98.5mm (L x B x H)
- ▶ Weight: ca. 7kg

Bench Top (BT)



Bench Mounted (BM)



REQUIRED MEDIA

- > 230 VAC 50/60Hz 10A (350W)
- ► Technical vacuum, tube Ø6/4mm (-0.8bar)
- ▶ BT air outlet for exhaust fan
- ▶ BM exhaust connector







If you would like a personal consultation or have a specific request, please do not hesitate to call us. Our technical experts will be pleased to help you.

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